# Synthesis and characterization of Tio<sub>2</sub> thin films doped with copper to be used in photocatalysis

# Síntesis y caracterización de películas delgadas de Tio<sub>2</sub> dopadas con cobre para ser usadas en fotocatálisis

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Abstract- In this work we studied the influence of incorporation of copper into TiO, thin films on structural, optical and surface properties of TiO, thin films. The as-grown TiO, was synthesized by sol gel method using titanium isopropoxide, and the TiO, thin films were deposited by spin coating method. TiO, copper-doped (Cu:TiO<sub>2)</sub> was synthesized by impregnation method using Cu(NO,).H,O as source of Cu(II), the Cu:TiO, thin films were deposited by spin coating method. The properties of the compounds obtained were evaluated by measurements of X-ray diffraction (XRD) and diffuse reflectance. The XRD results showed that Cu doping change the crystalline phase radio of the films, XRD pattern of TiO, indicated that films grow with anatase structute, while Cu:TiO, thin films presented a polycrystalline mixture of anatase/rutile. Reflectance analysis indicated that TiO presents an energy band gap of 3.25 eV and the Cu:Tio presents a shift-red of the band gap to 2,9 eV. The results suggest that doping with copper improved the harvesting of the TiO, to visible radiation.

**Keywords**— TiO<sub>2</sub>, Photocatalysis, metal doping, X-Ray, Diffuse Reflectance.

# **I. INTRODUCTION**

Nowadays the uncontrolled growth of the population increases both the water consumption and the amount of pollutants in the water resources; water treatment is an important research topic around the world. The development of mechanisms of water treatment is a necessity because water is not a renewable resource [1]. In the last decades, advanced oxidation processes (AOPs) have presented different kinds of methodologies for remediation of water and heterogeneous photocatalysis have become a promising method for purification. In this field Titanium oxide (TiO<sub>2</sub>) is one of the most important photocatalytic materials. There currently exists a better understanding and improvement of catalytic reactions, which is a main driving force for surface investigations on TiO<sub>2</sub>. However, two drawbacks limit the practical application of TiO<sub>2</sub> technology: (a) it is effective only under ultraviolet irradiation ( $\lambda$  < 380 nm) and (b) the low-quantum efficiency of this process [2]. To solve these, different methodologies have been used: sensitization with organic dyes, natural and synthetic [3], metal ion implantation [4] nobel metal loading [5], metal ion doping [6], anion doping [7], composite semiconductors [8]. All of these present both advantages and drawbacks, however, metal ion doping is one of

the most promising because it shifts the TiO, responses towards longer wavelengths and an enhanced photoactivity is obtained from incorporation of metallic dopants. These advantages can be explained because a dopant ion acts as an electron trap or hole trap; this could prolong the lifetime of the generated charge carriers, resulting in an enhancement of photocatalytic activity [9, 10]. The ionic metallic doping could be done through different ways such as hydrotermal precipitation [11], sol-gel [12], chemical vapor deposition [13], impregnation method [14] and sputtering [15]. The impregantion method has proven to be convenient for the modification of TiO<sub>2</sub> due to its low cost of implementation, the low synthesis temperatures, and because it easily allows the coating large areas.

In this work, we studied the influence of incorporation of Cu into  $\text{TiO}_2$  on its structural, optical properties.

### **II. EXPERIMENTAL**

### A. Materials synthesis

The as-grown TiO<sub>2</sub> Thin films were synthesized by the sol-gel method for the as-grown TiO, synthesis, the titanium isopropoxide  $[Ti(OC_{2}H_{z})_{4}]$ was used as reagent, ethanol (CH<sub>2</sub>CH<sub>2</sub>OH) and water were used as solvent and nitric acid (HNO<sub>2</sub>) was used as buffer. The molar ratio was [CH<sub>3</sub>CH<sub>2</sub>OH:H<sub>2</sub>O:HNO<sub>3</sub>:Ti(OC<sub>2</sub>H<sub>5</sub>)<sub>4</sub>] 55:1,5:0,3:1 respectively. The Cu:TiO, powder was obtained by adding copper (II) nitrate and titanium tetrachloride as source of copper and titanium respectively; furthermore, HCI was used as a buffer solution, a solution of cetyltrimethyl ammonium bromide (CATBr) was used as surfactant and water-ethanol mix was used as solvent in the following molar ratio [Ti:CATBr:HCl:H\_0:EtO:Cu] 1:0,16:1,7:1,7:20:0,025 respectively. The asgrown TiO, and the Cu:TiO, thin films were deposited on the substrates from a coating solution by spin-coating technique in a nitrogen atmosphere. The substrates coated with films were annealed at 450°C for 1 hour in air.

# B. Characterization of materials synthesized

The X-ray powder diffraction (XRD) patterns were recorded in X-ray powder diffractometer (MSAL-XDII) using  $K_{\alpha}$  radiation of the Cu ( $\lambda$ 

=0,15406nm) for operating at a 30 kV voltage with a current of 20 mA. The optical properties of the as-grown  $TiO_2$  and the  $Cu:TiO_2$  thin films were studied through diffuse reflectance measurements. The diffuse reflectance absorption spectrum of the as-grown  $TiO_2$  and the  $Cu:TiO_2$ thin films were measured using a Lambda 4 Perkin Elmer spectrophotometer equipped with an integrating sphere. Kubelka–Munk model and analysis based on differential reflection spectra were used to independently determine the energies of the fundamental optical transitions. FT-IR spectra (KBr) of the compounds were recorded on a Bruker Tensor 27 spectrometer in the spectrum region of 3500-500 cm<sup>-1</sup>.

# **III. RESULTS AND DISCUSSION**

# A. Diffuse transmittance measurements

The optical properties of the as-grown  $\text{TiO}_2$  thin film and  $\text{Cu:TiO}_2$  thin films were determined from diffuse reflectance measurements in the range of 200–800 nm. Fig. 1(a) shows the diffuse reflectance spectra of the as-grown  $\text{TiO}_2$  thin films, The results indicate that about 70% of the visible radiation is reflected in the visible range (after 350nm). Furthermore, a sharp absorption edge is observed near to the 340 nm, indicating the good crystallinity and a low defect density near to the band edge. This behavior is typical of thin films of  $\text{TiO}_2$  [16]. The results of diffuse reflectance spectra were analyzed with Kubelka-Munk remission function, given by the equation below [17]:

$$F(R_{\alpha}) = \frac{(1 - R_{\alpha})^2}{2R_{\alpha}} \tag{1}$$

Where  $R_{\alpha}$  is the reflectance and  $F(R_{\alpha})$  is proportional to the constant absorption of the material, an indicative of the absorbance of the sample in a particular wavelength. The optical band gap of the films was determined by extrapolating the linear portion of the  $(\alpha hv)^2$  versus hv plot on the x-axis [18].

$$(\alpha hv)^2 = A(hv - E_{\alpha}) \tag{2}$$

Where Eg is the band gap energy and A is a constant depending on the transition probability.





Fig.1(b) shows the  $(\alpha hv)^2$  versus hv for the as grown TiO<sub>2</sub> thin films and Cu:TiO<sub>2</sub> thin films

Fig. 2. XRD PATTER OF  ${\rm TiO}_2$  THIN FILMS DEPOSITED BY SOL-GEL METHOD,  ${\rm TiO}_2$  CU-DOPED AND JCSPD-ANATASE REFERENCE.



It is observed that the band gap of as-grown  $TiO_2$  thin film was 3,25 eV, which corresponds to the typical value of energy of the anatase  $TiO_3$ ; this

result is according to XRD measurements presented afterwards. The results also show a shift of absorption band edge towards visible region upon doping  $\text{TiO}_2$  with copper,  $\text{Cu:TiO}_2$  thin films present a band gap energy of 2,9 eV. These results suggest that copper could be incorporated into the crystalline TiO<sub>2</sub> network modifying its band structure and therefore its electrical properties. According to the optical results, it can be assumed that Cu-doping onto TiO<sub>2</sub> may enhance the visible-light absorption and it could improve the photocatalytic activity of TiO<sub>2</sub>.

## **B. XRD measurements**

Fig. 2 shows experimental XRD pattern corresponding to as-grown TiO, thin films and the Cu:TiO, thin films deposited on soda lime glass substrates by spin coating. The XRD measurements show that as-grown TiO, thin films were polycrystalline and present only one crystalline phase corresponding to the anatase phase (Fig. 1 includes a JCPDS-#071-1166 pattern of reference), the pattern of as-grown TiO, thin films presents different planes of growth and all diffraction signals correspond to the anatase-pattern indicating that only one crystalline phase is present. Furthermore, XRD results showed that the as-grown TiO, thin films grow in a preferential orientation in the crystalline plane (110), typical of the anatase phase. These results could occur due to the method used to obtain the compound, according to other reports [19]. Fig. 2 also shows the XRD pattern of the Cu:TiO<sub>2</sub>. The diffraction pattern shows three additional diffraction signals at 20=27,9, 20=37,9,  $2\theta=42,4,\ 2\theta=56,9$ ; these reflections can be associated with the planes (110), (101), (111) and (220) respectively. These crystalline planes can be associated with the rutile phase (JCPDS #021-1276); this happens because the rutile phase is thermodynamically the most stable crystalline phase and it possesses the highest density with a compact atomic structure. The presence of Cu is a disadvantage for the formation of the metastable anatase phase and so the rutile growth can occur [20]. Furthermore, not a signal associated with CuO or compund of Cu is observed, indicating that the compound could be amorfous or that it could be incorporated in the crystalline network of the doped TiO<sub>2</sub>. However, the change in the way of the crystalline growth indicates that the Cu participates in the growth of the  $TiO_2$  and it could be incorporated in the crystalline network of the final compoud according to other reports. This assertion is comfirmed for optical results [21].

Fig. 3. IR-SPECTRA OF THE AS-GROWN TIO, AND CU:TIO, THIN FILMS



#### C. IR measurements

Fig. 3 shows the IR-spectra of the as-grown TiO, films annealed at 500°C. The chemical bonding of the powders was scrutinized by correlating the developed peaks in the spectrum to the vibration or stretching of various functional groups. Results show two strong absorption signals in the frequency region of 429,1 cm<sup>-1</sup> and 734,7 cm<sup>-1</sup> corresponds to Ti-O-Ti bonding and indicates the formation of a titanium oxide network [22], furthermore, a broad band at 3400 cm<sup>-1</sup> is observed, which is characteristic of associated hydroxyl groups (absorbed molecular water), weakly chemisorbed and disappearing at temperatures of 200°C; a corresponding weak bending vibration band at near 1630 cm<sup>-1</sup> is also observed [23]. Finally, fig 3 shows the IR spectra of the Cu:TiO, thin films. In these spectra the intensity of the signals of  $\text{TiO}_2$  decrease significantly, indicating that water has been desorbed and not a signal associated to the stretching mode of Cu-O is detected, which demonstrates that copper could have been incorporated into the TiO, network as proved by the optical results.

#### **III. CONCLUSIONS**

Thin films of  $\text{TiO}_2$  were doped with copper and the optical and structural properties were investigated. The optical results indicated that  $\text{TiO}_2$  do-

ped with copper presents a red-shift of the transmittance spectra increasing the absorption of the photocatalyst in the visible region. The band gap increased by about 12% from 3.25 eV TiO<sub>2</sub> to 2,9 eV TiO<sub>2</sub> doped with copper. The XRD analysis showed that TiO<sub>2</sub> grows in the anatase phase while thin films of TiO<sub>2</sub> doped with copper present a polycrystalline mixture of anatase, rutile, and brookite. Results indicated that TiO<sub>2</sub> doped with copper can be used as an active photocatalyst in a visible range of the electromagnetic spectra.

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